

20. The composition of claim 19 which has a softening point of greater than 750°C.

21. The composition of claim 19 which has a thermal expansion coefficient α_{20-300} of between 60 and $88 \times 10^{-7} \text{ } ^\circ\text{C}^{-1}$.

22. The composition of claim 19 which has a strain point of greater than 570°C.

23. The composition of claim 19 wherein the working point is less than 1190°C, the softening point is at least 805°C, the thermal expansion coefficient is between 75.6 and $86 \times 10^{-7} \text{ } ^\circ\text{C}^{-1}$, and the strain point is between 580 and 590°C.

24. The composition of claim 19 wherein the ϕ coefficient satisfies the relationship

$$0.7 \text{MPa}^2 / ^\circ\text{C}^2 < \phi^2 \cdot c/a < 2 \text{MPa}^2 / ^\circ\text{C}^2$$

25. The composition of claim 19, comprising the following components:

| | |
|--------------------------------|--------|
| SiO ₂ | 55-75% |
| Na ₂ O | 5-10% |
| CaO | 8-12% |
| Al ₂ O ₃ | 0-7% |
| ZrO ₂ | 0-8% |
| K ₂ O | 0-8% |

26. The composition of claim 19 comprising the following components:

| | |
|--------------------------------|--------|
| SiO ₂ | 55-75% |
| Na ₂ O | 2-8% |
| K ₂ O | 2-8% |
| CaO | 4-11% |
| Al ₂ O ₃ | 0-7% |
| ZrO ₂ | 0-8% |
| MgO | 0-4% |

27. The composition of claim 19 comprising the following components:

| | |
|--------------------------------|----------|
| SiO ₂ | 55-75% |
| ZrO ₂ | 3-8% |
| Na ₂ O | 4.5-8% |
| K ₂ O | 3.5-7.5% |
| CaO | 7-11% |
| Al ₂ O ₃ | 0-5% |

28. The composition of claim 19, comprising the following components:

| | |
|--------------------------------|----------|
| SiO ₂ | 64.5-75% |
| ZrO ₂ | 3-7.5% |
| Na ₂ O | 5-9% |
| K ₂ O | 3.5-7.5% |
| CaO | 5-11% |
| SrO | 3-9% |
| Al ₂ O ₃ | 0-1% |
| MgO | 0-2% |
| BaO | 0-1.5% |

29. The composition of claim 19, wherein ϕ is between 0.75 and 0.84, and having a strain point of greater than 507°C and an electrical resistivity such that $\log \rho_{(250^\circ)}$ is greater than 6.6.

30. The composition of claim 29 wherein the strain point is between 530 and 590°C and the electrical resistivity is such that $\log \rho_{(250^\circ)}$ is greater than 8.

31. An article comprising the glass composition of claim 19.

32. The article of claim 31 in the form of a monolithic glazing panel, a plasma-screen substrate, an electroluminescent-screen substrate; an electroluminescent-screen substrate or a cold-cathode-screen substrate.